



Non-thermal Technologies in Food Science, Volume II

Guest Editors:

Prof. Dr. César Ozuna

Food Department, Division of Life Sciences, Campus Irapuato-Salamanca, University of Guanajuato, Guanajuato, Mexico

Prof. Dr. Sueli Rodrigues

Department of Food Engineering, Federal University of Ceara, Fortaleza 60440-900, CE, Brazil

Prof. Dr. Fabiano André

Narciso Fernandes

Departamento de Engenharia Química, Universidade Federal do Ceará (UFC), Fortaleza 60440-900, CE, Brazil

Deadline for manuscript submissions:

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Message from the Guest Editors

With the success of the previous Special Issue, “Non-thermal Technologies in Food Science”, we decided to organize a second Special Issue on this subject: “Non-thermal Technologies in Food Science, Volume II”. This Special Issue on “Non-thermal Technologies in Food Science, Volume II” is seeking original and high-quality papers that focus on the latest advances in the use of non-thermal technologies in the development of diverse food processes, healthy and nutritious products, and novel food ingredients. The topics include, but are not limited to the following:

- High hydrostatic pressure;
- Ozone;
- Plasma;
- Pulsed electric fields;
- Pulsed light;
- Supercritical carbon dioxide;
- Ultrasound;
- UV-C irradiation.





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Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and
Technology, University of Turin,
Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

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Processes Editorial Office
MDPI, St. Alban-Anlage 66
4052 Basel, Switzerland

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